	Application No.	Applicant(s)	
Notice of Allowability	10/624,564 Examiner	HIRAO, SHUJI Art Unit	
	Edna Wong	1753	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT IN of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in this a	pplication. If not inclu on will be mailed in du	ided e course. <b>THIS</b>
1. $\boxtimes$ This communication is responsive to <u>Amendment dated L</u>	<u>December 28, 2006</u> .		
2. X The allowed claim(s) is/are <u>1-8,10,11 and 31-36</u> .			U
3.  Acknowledgment is made of a claim for foreign priority to a)  All b)  Some* c)  None of the:  1.  Certified copies of the priority documents have 2.  Certified copies of the priority documents have 3.  Copies of the certified copies of the priority documents have 1.  Certified copies of the priority documents have 2.  Certified copies of the priority documents have 3.  Copies of the certified copies of the priority documents have 1.  Certified copies not received:  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  4.  A SUBSTITUTE OATH OR DECLARATION must be subminified in the part of the priority of the Notice of Draftspell (a)  including changes required by the Notice of Draftspell (b)  including changes required by the Notice of Draftspell (b)  including changes required by the attached Examined Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in DEPOSIT OF and/or INFORMATION about the department of the partment of the paper No.  Pape	ve been received. ve been received in Application No ocuments have been received in this  " of this communication to file a reply MENT of this application.  mitted. Note the attached EXAMINEI ves reason(s) why the oath or declar ust be submitted. rson's Patent Drawing Review ( PTC r's Amendment / Comment or in the  1.84(c)) should be written on the draw the header according to 37 CFR 1.121 osit of BIOLOGICAL MATERIAL	y complying with the reaction is deficient.  O-948) attached  Office action of rings in the front (not the left).	equirements  NOTICE OF  he back) of
attached Examiner's comment regarding REQUIREMENT	FOR THE DEPOSIT OF BIOLOGIC	CAL MATERIAL.	
Attachment(s)  1. ☑ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	Paper No./Mail Da 7. ⊠ Examiner's Amend	y (PTO-413), ate Iment/Comment	llowance
		EDNA WON	MINER

Art Unit: 1753

## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

## IN THE SPECIFICATION

page 8, line 20, the word "doe" has been deleted and replaced with the word -- does --.

## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Claims 1-8, 10-11 and 31-35 are allowable over the prior art of record because the prior art does not teach or suggest a method for plating a substrate comprising the steps of performing, rotating, rotating and performing as presently claimed, esp., the step of performing a first electrolytic plating process with respect to the substrate in a plating solution until at least one of depressed portions provided in a surface to be plated having a minimum diameter is filled up.

Claim **36** is allowable over the prior art of record because the prior art does not teach or suggest a method for manufacturing a semiconductor device comprising the steps of performing, rotating, rotating and performing as presently claimed, esp., the

step of performing a first electrolytic plating process with respect to a substrate in a plating solution until at least one of depressed portions provided in a surface to be plated having a minimum diameter is filled up.

The prior art does not contain any language that teaches or suggests the above. Grandikota et al. do not teach performing a first electrolytic plating process with respect to the substrate in a plating solution until at least one of depressed portions provided in a surface to be plated having a minimum diameter is filled up. Therefore, a person skilled in the art would not have been motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Citations

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

**Rodbell et al.** (US Patent No. 6,344,129 B1) is cited to teach a dual-step deposition process for depositing copper conductors in features that have large aspect ratios (col. 3, lines 38-60).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 4:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

> Primary Examiner Art Unit 1753

EW February 12, 2007